

**PRO**  
**06/90**  
**87%**

ISSUE CLASSIFICATION	
Class	Subclass

**PATENT NUMBER**

**U.S. UTILITY Patent Application**

AK SCANNED 5/23/2	O.I.P.E. NSA as CMI	PATENT DATE
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APPLICATION NO. 09/901416	CONT/PRIOR	CLASS 438	SUBCLASS	ART UNIT 2812 2813	EXAMINER
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**TITLE** Dual hardmask process for the formation of copper/low-k  
interconnects

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PTO-2040  
12/89[illegible]

<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>	<b>DRAWINGS</b>			<b>CLAIMS ALLOWED</b>	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) _____ (Date)			<b>NOTICE OF ALLOWANCE MAILED</b>	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____ _____ _____				<b>ISSUE FEE</b>	
				Amount Due	Date Paid
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Primary Examiner) _____ (Date)			<b>ISSUE BATCH NUMBER</b>	
_____ (Legal Instruments Examiner) _____ (Date)					
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